

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Confirmation No.
Akira NAKASHIMA et al. :
U.S. Patent Application No.: ----- Group Art Unit: -----
Filed: *herewith* :
:

For: METHOD OF FORMING AMORPHOUS SILICA-BASED COATING FILM WITH
LOW DIELECTRIC CONSTANT AND THUS OBTAINED SILICA-BASED
COATING FILM

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Preliminary to examination of the above-referenced application, please amend the application as follows:

AMENDMENTS TO THE SPECIFICATION

AMENDMENTS TO THE CLAIMS:

REMARKS